

IV. AMENDMENTS TO THE CLAIMS

1. (Currently Amended) A sparkling laminate film comprised of a sparkling laminate film body including a transparent surface substrate, a metal vapor deposited layer structure comprised of a first vapor deposited layer of an alloy consisting essentially of nickel, chromium, molybdenum and tungsten formed on a back surface of said transparent surface substrate and a second vapor deposited layer of chromium or chromium alloy successively formed on a back surface of said ~~transparent surface substrate~~first vapor deposited layer, and a backing material integrally laminated with said ~~metal~~second vapor deposited layer through an adhesive layer,

wherein the transparent surface substrate having a transparent surface substrate thickness in an approximate range of 15 and 100 μm , the first vapor deposited layer having a first vapor deposited layer thickness of at least 50Å, the second vapor deposited layer having a second vapor deposited layer thickness of at least 150Å and the metal vapor deposited layer structure having a metal vapor deposited layer structure thickness being a total of the first vapor deposited layer thickness and the second vapor deposited layer thickness in an approximate range of 200 to 750Å.

2. (Currently Amended) A sparkling laminate film comprised of a sparkling laminate film body including a transparent surface substrate, a metal vapor deposited layer structure comprised of a first vapor deposited layer of an alloy consisting essentially of nickel, chromium, molybdenum and tungsten formed on a back surface of said transparent surface substrate and a second vapor deposited layer of titanium or titanium alloy successively formed on a back surface of said ~~transparent surface substrate~~first vapor deposited layer, and a backing material integrally laminated with said ~~metal~~second vapor deposited layer through an adhesive layer,

wherein the transparent surface substrate having a transparent surface substrate thickness in an approximate range of 15 and 100 μm , the first vapor

deposited layer having a first vapor deposited layer thickness of at least 50Å, the second vapor deposited layer having a second vapor deposited layer thickness of at least 150Å and the metal vapor deposited layer structure having a metal vapor deposited layer structure thickness being a total of the first vapor deposited layer thickness and the second vapor deposited layer thickness in an approximate range of 200 to 750Å.

3. (Currently Amended) A sparkling laminate film comprised of a sparkling laminate film body including a transparent surface substrate, a metal vapor deposited layer structure comprised of a first vapor deposited layer of an alloy consisting essentially of nickel, chromium, molybdenum and tungsten formed on a back surface of said transparent surface substrate and a second vapor deposited layer of nickel or nickel alloy successively formed on a back surface of said ~~transparent surface substrate~~first vapor deposited layer, and a backing material integrally laminated with said ~~metal~~ second vapor deposited layer through an adhesive layer,

wherein the transparent surface substrate has a transparent surface substrate thickness in an approximate range of 15 and 100 μm, the first vapor deposited layer has a first vapor deposited layer thickness of at least 50Å, the second vapor deposited layer has a second vapor deposited layer thickness of at least 150Å and the metal vapor deposited layer structure has a metal vapor deposited layer structure thickness being a total of the first vapor deposited layer thickness and the second vapor deposited layer thickness in an approximate range of 200 to 750Å.

4. (Canceled)

5. (Original) A sparkling laminate film as set forth in any one of claims 1 to 3, wherein a hue angle (H°) when measuring the color of said transparent surface substrate is in a range of 245 to 265.

6. (Currently Amended) A sparkling laminate film as set forth in any one of claims 1 to 3, wherein said transparent surface substrate is a fluorine- or polyester-based film ~~of a thickness of 15 to 100 μm .~~

7. (Original) A sparkling shaped article comprised of a shaped body and a sparkling laminate film as set forth in any one of claims 1 to 3 integrally bonded to a surface of that body.

8. (New) A sparkling laminate film comprised of a sparkling laminate film body including a transparent surface substrate being a fluorine- or polyester-based film, a metal vapor deposited layer structure comprised of a first vapor deposited layer of an alloy consisting essentially of nickel, chromium, molybdenum and tungsten formed on a back surface of said transparent surface substrate and a second vapor deposited layer of chromium or chromium alloy successively formed on a back surface of said first vapor deposited layer, and a backing material integrally laminated with said second vapor deposited layer through an adhesive layer,

wherein the transparent surface substrate has a hue angle (H°) in a range of 245 to 265 and a transparent surface substrate thickness in an approximate range of 15 and 100 μm , the first vapor deposited layer has a first vapor deposited layer thickness of at least 50Å, the second vapor deposited layer has a second vapor deposited layer thickness of at least 150Å and the metal vapor deposited layer structure has a metal vapor deposited layer structure thickness being a total of the first vapor deposited layer thickness and the second vapor deposited layer thickness in an approximate range of 200 to 750Å.